

Attorney Docket: 081468-0354685

Client Reference: P-1775.010-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:
THEODORUS MARINUS MODDERMAN ET AL.

Confirmation Number: 8421

Application No.: 10/583,985

Group Art Unit: 2877

Filed: June 4, 2007

Examiner: UNKNOWN

Title: LITHOGRAPHIC APPARATUS, METHOD OF EXPOSING A SUBSTRATE, METHOD OF MEASUREMENT, DEVICE MANUFACTURING METHOD, AND DEVICE MANUFACTURED THEREBY

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR CORRECTED FILING RECEIPT

Attached is a copy of the official filing receipt from the PTO in the above application for which issuance of a corrected filing receipt is respectfully requested. There is an error with respect to the following data which is incorrectly entered.

Error in

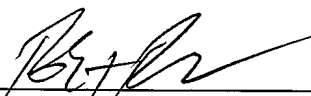
Title

Correct data

LITHOGRAPHIC APPARATUS, METHOD OF EXPOSING A SUBSTRATE, METHOD OF MEASUREMENT, DEVICE MANUFACTURING METHOD, AND DEVICE **MANUFACTURED** THEREBY

Respectfully submitted,

PILLSBURY WINTHROP SHAW PITTMAN LLP



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APPL NO.	FILING OR 371(c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	TOT CLMS	IND CLMS
10/583,985	06/04/2007	2877	3380	081468-0354685	51	7

CONFIRMATION NO. 8421

909
 PILLSBURY WINTHROP SHAW PITTMAN, LLP
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FILING RECEIPT



OC000000024954695

Date Mailed: 07/24/2007

Receipt is acknowledged of this nonprovisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER; FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).**

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Assignment For Published Patent Application

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Power of Attorney: The patent practitioners associated with Customer Number 00909.

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PILLSBURY WINTHROP SHAW PITTMAN

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/NL04/00900 12/22/2004

JUL 25 2007

Foreign Applications

CL 081468 MT# 0354685
 ATTY(S) JSB, VIEB, RRP
 DUE:
 DKT BY(1) LH (2) JH

If Required, Foreign Filing License Granted: 07/20/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/583,985**

Projected Publication Date: 11/01/2007

Non-Publication Request: No

Early Publication Request: No

Title

Lithographic Apparatus, Method of Exposing a Substrate, Method of Measurement, Device
Manufacturing Method, and Device Manufacturing Thereby

Manufactured

Preliminary Class

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Title 37, Code of Federal Regulations, 5.11 & 5.15

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